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	1	АВ	4	2	8	4	6	1	8	18AUG81	van der HEYDEN et al.	—		
	1	AC	4	4	7	6	1	0	4	09OCT84	MELLORS			
		AD	4	6	6	7	4	1	7	26MAY87	GRASER et al.			
		AE	4	8	9	4	3	5	7	16JAN90	HUPE et al.			
		AF	5	1	3	5	7	3	2	04AUG92	BARBOUX et al.			
		AG	5	1	5	6	9	3	4	200CT92	KAINTHIA et al.			
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		AJ	5	2	7	5	7	9	6	04JAN94	TILLOTSON et al.			
		AK	5	3	9	5	8	0	5	07MAR95	DROEGE et al.			
		AL	5	4	0	9	6	8	3	25APR95	TILLOTSON et al.			
		AM.	5	6	0	1	9	5	2	11FEB97	DASGUPTA et al.			
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8)	13	AT	Y. C	Y. Chabre and J. Pannetier, Progress in Solid State Chemistry, 1995, 23, 1-130, he month										
8"	YB.	AU	М. М	M. M. Thackeray, Progress in Solid State Chemistry, 1997, 25, 1-71, no month										
	M3	AV	J.J.	J.J. Xu, A. J. Kinser, B.B. Owens, and W.H. Smyrl, Electrochemical and Solid-State Letters, 1998, 1, 1-3, no mout										
34	MB	AW	S. Bach, J.P. Pereira-Ramos, N. Baffer, and r. Messina, Electrochimica Acta, 1992, 37, 1301, no month											
1	B	AX	H. Kurimoto, K. Suzuoka, T. Murakami, Y. Xia, H. Nakamura, and M. Yoshio, <i>Journal of the electrochemical Society</i> , 1995, 142, 2150-2162, Tuly											
& h	m	AY	A. Manthiram and J. Kim, Chemistry of Materials, 1998, 10, 2895-2909, no month											
8	h	AZ N. Husing and U. Schubert, Angewandte Chemie- International Edition, 1998, 37, 22-45, As month												
EXAM	INER		8	YB	<u>~</u>						DATE CONSIDERED	11/12	01	
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·		OTHER DOCUMENTS (include author,	title, name of publication, volume, pages and date of	f publication)	Ü					
1 MB	ВА	K. Sailoux, F. Chaput, H.P. Wong, B. Dunn, and M. W. Breiter, Journal of the Electrochemical Society, 1995, 142, L191-L192, he worth								
Sm	88	D.B. Le, S.Passerini, J. Guo, J. Ressler, 2099-2104, Jaly	B.B. Owens, and W.H. Smyrl, Journal of the Electron	chemical Society, 199	16, 143,					
e m	вс	D.B. Le, S.Passerini, A. L.Tipton, B.B. Owens, and W.H. Smyrl, Journal of the Electrochemical Society, 1995, 142, L102-								
8 m	BD	F. Coustier, S. Passerine and W.H. Smyrl, Journal of the Electrochemical Society, 1998, 145, L73-L74, May								
Sm	BE	J. H. Harreld, W. Dong, and B. Dunn, Materials Research Bulletin 1998, 33, 561-567, no month								
Sm	BF	S. Bach, M. Henry, N. Baffier, and J. Livage, Journal of Solid State Chemistry, 1990, 88, 325-333, no month								
syrs	BG	ZR. Tian, W. Tong, JY. Wang, NG. Duan, V. V. Krishnan, S. L. Suib, Science, 1997, 276, 926-930, May								
sm	ВН	J. Luo and S. L. Suib, Journal of the Chemical Society- Chemical Communications, 1997, 1031-1032, no mon #								
SM	BI	W. Dong, et al., "Electrochemical and Solid-State Letters," 2000, 3, 457-459, Angust								
(m	BJ	J.W. Long, et al., "Electrochemical and Solid-State Letter," 2000, 3, 453-456, Angust								
Sm	BK	J. Koresh, et al., "Journal of the Electrochemical Society," 1977, 124, 1379-1385, no month								
SM	BL	S. Ardizzone, et al., "Journal of Electrochemical Society," 1982, 129, 1689-1693, no month								
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